

APPLICATION DATA SHEET

Electronic Version 0.0.11

Stylesheet Version: 1.0

Attorney Docket Number: 740756-2659

Publication Filing Type: new-utility

Application Type: utility

Title of Invention: METHOD FOR FABRICATING SEMICONDUCTOR THIN FILM

Legal Representative:

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Registration Number: 35483

Customer Number Correspondence Address: 22204

22204

Continuity Data:

This application is a division of 09/838,216 A1 2001-04-20 US PENDING

which is a reexamination of 09/115,838 A1 1998-07-15 US 6,071,766 A1 2000-06-06 US

which is a division of 08/536,977 A1 1995-09-29 US 5,789,284 A1 1998-08-04 US

Foreign Priority:

06-259117 JP 1994-09-29 Priority Claimed

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